

Temperature dependence of magnetoelectric switching condition of perpendicular exchange bias

° T. V. A. Nguyen,^{1,2} Y. Shiratsuchi,¹ S. Yonemura,³ T. Shibata,³ Y. Endo,² R. Nakatani¹

¹Grad. School of Eng., Osaka Univ., ²CSRN, Tohoku Univ., ³TDK corporation

E-mail: anh@ecei.tohoku.ac.jp, shiratsuchi@mat.eng.osaka-u.ac.jp

Recent progress in electric field induced switching of the perpendicular exchange bias (PEB) at the magnetoelectric (ME) Cr₂O₃/ferromagnetic interface has achieved the isothermally reversible PEB even for the all-thin-film systems [1,2]. To realize the application in spintronics devices, it is essential to clarify the energy condition of the ME switching of the PEB. So far, the relationship between the applied magnetic field H and threshold electric field E for the ME switching of PEB was suggested: $\alpha(E-E_0)H = \pm 2K_{\text{AFM}} - J_{\text{INT}}/t_{\text{AFM}}$ (eq.1) (where α is a ME coefficient of Cr₂O₃, K_{AFM} and t_{AFM} are magnetic anisotropy energy and thickness of the Cr₂O₃ layer, J_{INT} is the interface exchange coupling, and E_0 is the interfacial magnetization - induced electric field) [3]. While the previous researches on the ME switching were normally conducted at a certain temperature below the Néel temperature (T_N), in this study, to obtain a deeper understanding of the effect, we examined the temperature dependence of the energy condition for ME switching of PEB.

The Pt(1.2 nm)/Co(0.4 nm)/Au(0.5 nm)/Cr₂O₃(173 nm)/Pt(20 nm) stacked film was fabricated by using DC magnetron sputtering. The electric-field induced ME switching was investigated at different temperatures T (from 284 K to 296 K) by the anomalous Hall effect measurements, following the reversible isothermal approach. Using eq.1, we estimated the temperature T dependence of K_{AFM} , J_{INT} , E_0 . Fig. 1 shows that K_{AFM} , J_{INT} , E_0 decrease as T increases. We compared the T dependence of J_{INT} with that of J_K , where J_K was calculated using the exchange bias field and the saturation magnetization per unit area (Fig. 1b). The result shows a bifurcated tendency between them at $J_{\text{INT}} \sim 0.02$ - 0.03 mJ/m², suggesting a clear restriction of J_K by the magnetic domain wall energy of the AFM layer.

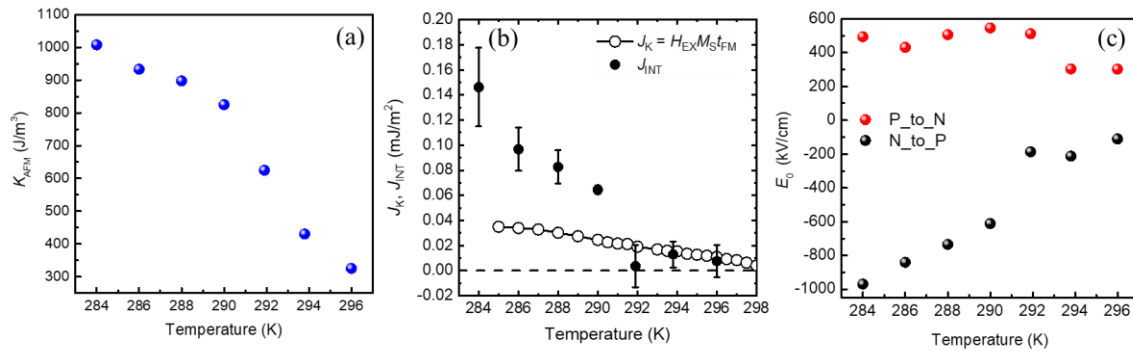


Fig. 1: Temperature dependence of (a) K_{AFM} ; (b) J_{INT} and J_K ; (c) E_0

References: (1) T. Ashida et al., Appl. Phys. Lett. **106**, 132407, (2015).; (2) K. Toyoki et al., Appl. Phys. Lett. **106**, 162404, (2015).; (3) T. V. A. Nguyen et al., J. Appl. Phys. **122**, 073905, (2017);